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Application No.: 10/603,924

APR - 4 2006

Docket No.: JCLA7109

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Examiner: NGUYEN,THANH T

Group Art Unit: 2813

In re PATENT APPLICATION of
Applicants: Shao-Chung Hu
)
Serial No.: 10 / 603,924
)
Filed: June 24, 2003
For: POST-CMP REMOVAL OF SURFACE CONTAMINATS FROM SILICON WAFER

AMENDMENT AFTER FINAL

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

The Office Action mailed December 5th, 2005 has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.